

East Search

L Number	Hits	Search Text	DB	Time stamp
1	2536	cure near5 develop\$5	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 13:22
2	4924	(acid photoacid) adj generator	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 13:23
3	116371	(infrared IR) adj absorb\$3 (carbon adj black)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 13:24
4	2	("4943511").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 13:24
-	11344	(infrared IR) near (absorb\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/18 13:21
-	14081	\$5acid near generat\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 12:32
-	3	dual adj polymer near binder	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 12:39
-	3012981	polymer binder resist photoresist resin	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 12:39
-	367	((infrared IR) near (absorb\$4)) and (\$5acid near generat\$4) and (polymer binder resist photoresist resin)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 12:40
-	55158	(phenol \$2cresol (p-hydroxy adj benzoic) (2-naphthol)) and (catechol resorcinol hydroquinone (bisphenol adj A.u/c.) (bisphenol adj B.u/c.) trihydroxybenzene)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 13:16
-	250258	aldehyde formaldehyde acetaldehyde fural benzaldehyde	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 12:43
-	117	((infrared IR) near (absorb\$4)) and (\$5acid near generat\$4) and (polymer binder resist photoresist resin)) and ((phenol \$2cresol (p-hydroxy adj benzoic) (2-naphthol)) and (catechol resorcinol hydroquinone (bisphenol adj A.u/c.) (bisphenol adj B.u/c.) trihydroxybenzene)) and (aldehyde formaldehyde acetaldehyde fural benzaldehyde)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 12:43
-	167838	(carbon adj black) (pyridyl quinolinyl benzoxazolyl thiazolyl benothiazolyl oxazolyl selenazolyl)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/31 15:12
-	51388	sulfonium sulfoxonium arsonium iodonium diazonium bromonium selenonium phosphonium	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 12:45
-	582115	(expos\$4 irradiat\$4 image-wise image) and (develop\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 12:46
-	3251221	heat cure \$5bake \$5baking curing heating	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 12:46

-	79	((((infrared IR) near (absorb\$4)) and (\$5acid near generat\$4) and (polymer binder resist photoresist resin)) and ((phenol \$2cresol (p-hydroxy adj benzoic) (2-naphthol)) and (catechol resorcinol hydroquinone (bisphenol adj A.u/c.) (bisphenol adj B.u/c.) trihydroxybenzene)) and (aldehyde formaldehyde acetaldehyde fural benzaldehyde)) and ((carbon adj black) (pyridyl quinolinyl benzoxazolyl thiazolyl benothiazolyl oxazolyl selenazolyl)) and (sulfonium sulfoxonium arsonium iodonium diazonium bromonium selenonium phosphonium) and ((expos\$4 irradiat\$4 image-wise image) and (develop\$3)) and (heat cure \$5bake \$5baking curing heating)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 10:46
-	168946	(phenol \$2cresol (p-hydroxy adj benzoic) (2-naphthol)) and (catechol resorcinol hydroquinone (bisphenol adj A.u/c.) (bisphenol adj B.u/c.) trihydroxybenzene) same aldehyde formaldehyde acetaldehyde fural benzaldehyde	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 13:17
-	9655	(phenol \$2cresol (p-hydroxy adj benzoic) (2-naphthol)) and (catechol resorcinol hydroquinone (bisphenol adj A.u/c.) (bisphenol adj B.u/c.) trihydroxybenzene) same (aldehyde formaldehyde acetaldehyde fural benzaldehyde)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 13:18
-	107	((((infrared IR) near (absorb\$4)) and (\$5acid near generat\$4) and (polymer binder resist photoresist resin)) and ((phenol \$2cresol (p-hydroxy adj benzoic) (2-naphthol)) and (catechol resorcinol hydroquinone (bisphenol adj A.u/c.) (bisphenol adj B.u/c.) trihydroxybenzene) same aldehyde formaldehyde acetaldehyde fural benzaldehyde) and ((carbon adj black) (pyridyl quinolinyl benzoxazolyl thiazolyl benothiazolyl oxazolyl selenazolyl)) and (sulfonium sulfoxonium arsonium iodonium diazonium bromonium selenonium phosphonium) and ((expos\$4 irradiat\$4 image-wise image) and (develop\$3)) and (heat cure \$5bake \$5baking curing heating)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 13:53
-	46	nk-2014	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 14:09

-	32	(((((infrared IR) near (absorb\$4)) and (\$5acid near generat\$4) and (polymer binder resist photoresist resin)) and ((phenol \$2cresol (p-hydroxy adj benzoic) (2-naphthol)) and (catechol resorcinol hydroquinone (bisphenol adj A.u/c.) (bisphenol adj B.u/c.) trihydroxybenzene) same aldehyde formaldehyde acetaldehyde fural benzaldehyde) and ((carbon adj black) (pyridyl quinolinyl benzoxazolyl thiazolyl benothiazolyl oxazolyl selenazolyl) and (sulfonium sulfoxonium arsonium iodonium diazonium bromonium selenonium phosphonium) and ((expos\$4 irradiat\$4 image-wise image) and (develop\$3)) and (heat cure \$5bake \$5baking curing heating)) not (((infrared IR) near (absorb\$4)) and (\$5acid near generat\$4) and (polymer binder resist photoresist resin)) and ((phenol \$2cresol (p-hydroxy adj benzoic) (2-naphthol)) and (catechol resorcinol hydroquinone (bisphenol adj A.u/c.) (bisphenol adj B.u/c.) trihydroxybenzene)) and (aldehyde formaldehyde acetaldehyde fural benzaldehyde)) and ((carbon adj black) (pyridyl quinolinyl benzoxazolyl thiazolyl benothiazolyl oxazolyl selenazolyl) and (sulfonium sulfoxonium arsonium iodonium diazonium bromonium selenonium phosphonium) and ((expos\$4 irradiat\$4 image-wise image) and (develop\$3)) and (heat cure \$5bake \$5baking curing heating))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 15:22
-	1	write-the-background adj mode	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 15:22
-	1	(write-the-image) adj mode	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 15:23
-	2	(write-the-background adj mode) ((write-the-image) adj mode)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 15:29
-	17	ARIAS-A ARIAS-ANDRE-LUIZ ARIAS-A-L ARIAS-L ARIAS-LUIS ARIAS-LUIZ-NEI ARIAS-L-N ARIAS-M ARIAS-MARJORIE PROVENZANO-MARIO-ITALO PROVENZANO-M-I	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/27 15:39
-	23813	cyclohexanone same solvent	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/31 14:51
-	0	((bisphenol adj a.u/c. near2 formaldehyde) (m-cresol adj formaldehyde) (bisphenol adj a.u/c.-formaldehyde) (m-cresol-formaldehyde)) same (molecular adj weight)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/03/31 15:19
-	189263	((bisphenol adj a.u/c. near2 formaldehyde) (m-cresol adj formaldehyde) (bisphenol adj a.u/c.-formaldehyde) (m-cresol-formaldehyde))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/15 15:55
-	156517	(develop\$4) same (cur\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/04/01 09:19
-	2255	((develop\$4) same (cur\$4)) and (novolak resol)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/04/01 11:49

-	527	((((develop\$4) same (cur\$4)) and (novolak resol)) and (onium (\$5acid near generat\$3)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/04/01 11:49
-	53	((((develop\$4) same (cur\$4)) and (novolak resol)) and (onium (\$5acid near generat\$3))) and ((infrared IR) near3 absorb\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/04/01 11:49
-	36	(((((develop\$4) same (cur\$4)) and (novolak resol)) and (onium (\$5acid near generat\$3))) and ((infrared IR) near3 absorb\$3)) and (curing cure)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/04/01 09:19
-	24035	(develop\$4) same (cure curing cured)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/04/01 09:19
-	1597	((develop\$4) same (cure curing cured)) and (novolak resol)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/04/01 09:22
-	372	((((develop\$4) same (cure curing cured)) and (novolak resol)) and (onium (\$5acid near generat\$3)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/04/01 09:25
-	29	(((((develop\$4) same (cure curing cured)) and (novolak resol)) and (onium (\$5acid near generat\$3))) and ((infrared IR) near3 absorb\$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/04/01 11:39
-	3	cure adj after adj development	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/04/01 11:48
-	10564	cur\$3 near3 develop\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/04/01 11:49
-	410	(cur\$3 near3 develop\$4) and (novolak resol)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/04/01 11:49
-	130	((cur\$3 near3 develop\$4) and (novolak resol)) and (onium (\$5acid near generat\$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/04/01 11:49
-	2	((((cur\$3 near3 develop\$4) and (novolak resol)) and (onium (\$5acid near generat\$3))) and ((infrared IR) near3 absorb\$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 10:02
-	304	(resol resole) same (polyhydric)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/15 16:00
-	785	resorcinol same (resol resole)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/17 11:44
-	154	(resol resole) same (polyhydroxy dihydroxy poly-hydroxy di-hydroxy)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2003/12/17 12:42
-	2	((("5786125") or ("6042987"))).PN.	USPAT	2003/12/17 12:42
-	6	((((cur\$3 near3 develop\$4) and (novolak resol)) and (onium (\$5acid near generat\$3))) and ((infrared IR) near3 absorb\$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 10:03
-	2	ep-0501433-\$.did. us-4943511-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 12:44

-	140	((((infrared IR) near (absorb\$4)) and (\$5acid near generat\$4) and (polymer binder resist photoresist resin)) and ((phenol \$2cresol (p-hydroxy adj benzoic) (2-naphthol)) and (catechol resorcinol hydroquinone (bisphenol adj A.u/c.) (bisphenol adj B.u/c.) trihydroxybenzene)) and (aldehyde formaldehyde acetaldehyde fural benzaldehyde)) and ((carbon adj black) (pyridyl quinolinyl benzoxazolyl thiazolyl benothiazolyl oxazolyl selenazolyl)) and (sulfonium sulfoxonium arsonium iodonium diazonium bromonium selenonium phosphonium) and ((expos\$4 irradiat\$4 image-wise image) and (develop\$3)) and (heat cure \$5bake \$5baking curing heating) ep-0501433-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 10:47
-	0		USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 12:42
-	2	ep-501433-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 12:42
-	4	ep-501433-\$.did. us-4943511-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 12:44
-	0	(ep-501433-\$.did. us-4943511-\$.did.) and (infrared IR)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 12:45
-	0	(ep-501433-\$.did. us-4943511-\$.did.) and (absorber)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 12:45
-	2278370	polymer binder resist photoresist	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 12:45
-	110785	((infrared IR) adj absorber) (carbon adj black)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 12:46
-	15324	(photoacid acid) adj generat\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 12:46
-	728	(polymer binder resist photoresist) and (((infrared IR) adj absorber) (carbon adj black)) and ((photoacid acid) adj generat\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 12:46
-	395417	cresol phenol p-hydroxybenzoic (p-hydroxy adj benzoic) catechol resorcinol hydroquinone bisphenol trihydroxybenzene	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 12:48
-	190479	formaldehyde acetaldehyde fural benzaldehyde	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 12:48
-	328	((polymer binder resist photoresist) and (((infrared IR) adj absorber) (carbon adj black)) and ((photoacid acid) adj generat\$3)) and (cresol phenol p-hydroxybenzoic (p-hydroxy adj benzoic) catechol resorcinol hydroquinone bisphenol trihydroxybenzene) and (formaldehyde acetaldehyde fural benzaldehyde)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 12:48

-	275	((((polymer binder resist photoresist) and (((infrared IR) adj absorber) (carbon adj black)) and ((photoacid acid) adj generat\$3)) and (cresol phenol p-hydroxybenzoic (p-hydroxy adj benzoic) catechol resorcinol hydroquinone bisphenol trihydroxybenzene) and (formaldehyde acetaldehyde fural benzaldehyde)) and develop\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 12:48
-	232	((((polymer binder resist photoresist) and (((infrared IR) adj absorber) (carbon adj black)) and ((photoacid acid) adj generat\$3)) and (cresol phenol p-hydroxybenzoic (p-hydroxy adj benzoic) catechol resorcinol hydroquinone bisphenol trihydroxybenzene) and (formaldehyde acetaldehyde fural benzaldehyde)) and develop\$4) and (cur\$5)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 12:49
-	6568715	cur\$5 heat\$3 bak\$4 postbak\$4 post-bak\$4 (post adj bak\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 12:50
-	275	((((polymer binder resist photoresist) and (((infrared IR) adj absorber) (carbon adj black)) and ((photoacid acid) adj generat\$3)) and (cresol phenol p-hydroxybenzoic (p-hydroxy adj benzoic) catechol resorcinol hydroquinone bisphenol trihydroxybenzene) and (formaldehyde acetaldehyde fural benzaldehyde)) and develop\$4) and (cur\$5 heat\$3 bak\$4 postbak\$4 post-bak\$4 (post adj bak\$4))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 12:50
-	344633	develop\$4 same (cur\$5 heat\$3 bak\$4 postbak\$4 post-bak\$4 (post adj bak\$4))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 13:06
-	2	us-4943511-\$.did.	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 13:02
-	0	(alizarin adj yellow adj "A" adj dye) same (infrared IR)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 13:05
-	2	alizarin adj yellow adj "A" adj dye	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 13:05
-	180	alizarin adj yellow	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 13:05
-	0	(alizarin adj yellow) same (infrared IR)	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 13:06
-	243	(((((polymer binder resist photoresist) and (((infrared IR) adj absorber) (carbon adj black)) and ((photoacid acid) adj generat\$3)) and (cresol phenol p-hydroxybenzoic (p-hydroxy adj benzoic) catechol resorcinol hydroquinone bisphenol trihydroxybenzene) and (formaldehyde acetaldehyde fural benzaldehyde)) and develop\$4) and (cur\$5 heat\$3 bak\$4 postbak\$4 post-bak\$4 (post adj bak\$4))) and (develop\$4 same (cur\$5 heat\$3 bak\$4 postbak\$4 post-bak\$4 (post adj bak\$4)))	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 13:22
-	11151	after adj develop\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 13:22

-	27	<p> ((((polymer binder resist photoresist) and (((infrared IR) adj absorber) (carbon adj black)) and ((photoacid acid) adj generat\$3)) and (cresol phenol p-hydroxybenzoic (p-hydroxy adj benzoic) catechol resorcinol hydroquinone bisphenol trihydroxybenzene) and (formaldehyde acetaldehyde fural benzaldehyde)) and develop\$4) and (cur\$5 heat\$3 bak\$4 postbak\$4 post-bak\$4 (post adj bak\$4))) and (develop\$4 same (cur\$5 heat\$3 bak\$4 postbak\$4 post-bak\$4 (post adj bak\$4)))) and (after adj develop\$3) </p>	USPAT; US-PGPUB; EPO; JPO; DERWENT	2004/04/06 13:22
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